



ISPlasma2018 / IC-PLANTS2018

10th Anniversary International Symposium on Advanced Plasma Science
and its Applications for Nitrides and Nanomaterials /
11th International Conference on Plasma-Nano Technology & Science
Meijo University, Nagoya, Japan, March 4-8, 2018

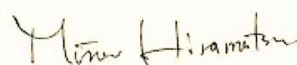
Best Presentation Award

in the area of Plasma Science

to

**H. ITAGAKI, S. HIROSE, Y. EZUKA, J. KIM, X.-L.
WANG AND H. SAKAKITA**

“Iron Nitriding by Quasi-atmospheric Microwave
Excited Nitrogen Radical Flow”



Mineo Hiramatsu
Chairperson of ISPlasma2018 / IC-PLANTS2018 Organizing Committee
Professor of Meijo University



Kenji Ishikawa
Chairperson of ISPlasma2018 / IC-PLANTS2018 Program Committee
Professor of Nagoya University